

**CERTIFICATE OF TRANSMISSION BY FACSIMILE (37 CFR 1.8)**Applicant(s): **William N. Partlo, et al.**

Docket No.

**2000-0086-01**

Serial No.

**09/716,041**

Filing Date

**November 17, 2000**

Examiner

**J. Nguyen**

Group Art Unit

**2815**

Invention:

**HIGH POWER GAS DISCHARGE LASER WITH HELIUM PURGED LINE NARROWING UNIT***4 Pages*

I hereby certify that this

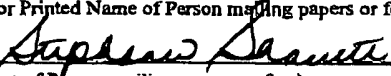
**Response to Final Office Action***(Identify type of correspondence)**308-7722/7724*is being facsimile transmitted to the United States Patent and Trademark Office (Fax. No. **703-305-1341**)**FAX RECEIVED**

on

**February 25, 2003***(Date)***FEB 25 2003****TECHNOLOGY CENTER 2800****Stephanie Sharrett***(Typed or Printed Name of Person Signing Certificate)**Stephanie Sharrett**(Signature)***Note: Each paper must have its own certificate of mailing.**

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## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:	)	Examiner: J. Nguyen
William N. Partlo, et al.	)	
Serial No.: 09/716,041	)	Group Art Unit: 2815
Filed: November 17, 2000	)	
For: HIGH POWER GAS DISCHARGE LASER	)	
WITH HELIUM PURGED LINE	)	
NARROWING UNIT	)	

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Commissioner for Patents  
Washington, D.C. 20231

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RESPONSE TO FINAL OFFICE ACTION

FEB 25 2003

Sir:

TECHNOLOGY CENTER 2800

This letter is in response to Office Action mailed November 26, 2002.

## REMARKS

The Examiner has rejected Applicants' claims based on an abandoned patent application ('374 Osamu) which was discredited by the authors' of the application. Applicants' requests reconsideration. The authors stated in a subsequent application that the technique referred to in the abandoned application would not work and "must be avoided". Under these circumstances the abandoned application is not a proper reference against Applicants' invention.